

CALL FOR PAPERS

The 3rd Asian Workshop on Nano/Micro Forming Technology: AWMFT 2010

Ramada Plaza Hotel, Jeju Island, Korea, October 7-8, 2010

Background

The Asian Nano/Micro Forming Workshop is a part of an exchange program organized by CSTP (China Society of Technology of Plasticity), JSTP (Japan Society of Technology of Plasticity) and KSTP (Korean Society of Technology of Plasticity). The workshop provides a chance for academics, researchers and engineers to meet and exchange information on all aspects of nano/micro forming technology. The 1st workshop was held simultaneously with the 57th Japanese Joint Conference for the Technology of Plasticity in Hokkaido, Japan. The 2nd workshop was held simultaneously with the 11th Chinese Annual Conference for the Technology of Plasticity, which is one of the biggest domestic conferences on technology of plasticity and metal forming in China. This year KSTP will organize the 3rd workshop in the beautiful Jeju island in the best season of the year.

Objectives

The workshop aims to provide an opportunity to discuss and exchange ideas on new applications for nano/micro forming as well as new technology developments. We assure that you will find your participation a rewarding experience for broadening your academic knowledge and for serving your personal needs.

Areas of special interest for discussion include:

- Micro forming processing
- Micro/nano scale effect
- Micro forming equipment
- Simulation of micro forming
- Measuring and controlling of micro forming
- Application of micro forming
- Formability of nano-crystalline materials
- Preparation and properties of nano materials

Important Dates

- **July 15, 2010** Submission of an extended abstract (max 400 words)
- **July 31, 2010** Communication of acceptance and grant eligibility
- September 15 2010 Submission of the full paper (max 6 pages)
- **October 7-8, 2010** **Workshop date**

Registration fee

100 US dollar, including Proceedings, welcoming party and banquet

Organizing Committee

Chinese members of organizing committee

Kai-Feng Zhang (HIT), Xin Lu (BRIMET), Shi-Hong Zhang (CAS-IMR), Bin Guo (HIT)
Xue-Ping Ren (USTB), Jian-Jun Li (HUST), Xiang-Huai Dong (SJTU),
Ke-Fu Yao (Tsinghua), Pan Zeng (Tsinghua)

Japanese members of organizing committee

Yasunori Saotome (Tohoku University), Naoto Ohtake(Tokyo Institute of Technology),
Shigekazu Tanaka (Shizuoka University), Ming Yang (Tokyo Metropolitan University),
Kazuhiko Kitamura (Nagoya Institute of Technology), Jun Yanagimoto (Tokyo
University), Hiroshi Utsunomiya (Osaka University)

Korean members of organizing committee

Chong Soo Lee (POSTECH), In Soo Kim (Kumoh National Institute of Technology),
Shinill Kang (Yonsei University), Doo Sun Choi (KIMM), Hyoung Seop Kim
(POSTECH) , Jung Hwan Lee (KIMS), Heon Young Kim (Kangwon National
University), Young Sang Na (KIMS)

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